L Number	Hits	Search Text	DB	Time stamp
1	8345	(reticle or mask) and (substrate or wafer) and synchron\$7	USPAT; US-PGPUB;	2002/12/04 13:29
			EPO; JPO; DERWENT	
2	449	((reticle or mask)and (substrate or wafer) and synchron\$7) and (illumination near10	USPAT; US-PGPUB;	2002/12/04 13:29
		chang\$4)	EPO; JPO; DERWENT	